










**IMPROVED POLISHING PADS AND METHODS FOR THEIR USE**

**Patent number:** WO9527595  
**Publication date:** 1995-10-19  
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**Classification:**  
- **International:** B24D11/00  
- **European:** A47L13/28; B24D3/28; B24D11/00B3; B24D11/02;  
B24D13/00  
**Application number:** WO1995US04072 19950330  
**Priority number(s):** US19940224768 19940408

**Also published as:**

 EP0701499 (A)  
 US5489233 (A)  
 EP0701499 (A)  
 EP0701499 (B)

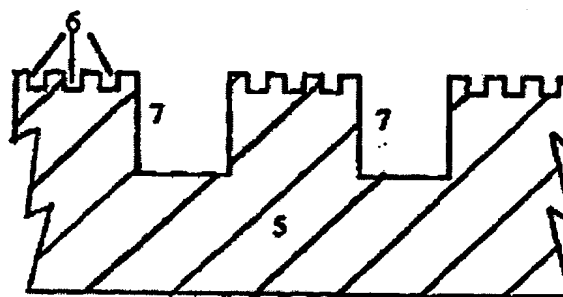
**Cited documents:**

 US4055029  
 US4111666  
 US5177910  
 US4271272  
 US4421526  
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**Abstract of WO9527595**

An improved polishing pad is provided comprising a solid uniform polymer sheet (5) having no intrinsic ability to absorb or transport slurry particles having during use a surface texture or pattern which has both large (7) and small (6) flow channels present simultaneously which permit the transport of slurry across the surface of the polishing pad, where said channels are not part of the materials structure but are mechanically produced upon the pad surface. In a preferred version of the invention, the pad texture consists of a macrotexture produced prior to use and a microtexture which is produced by abrasion by a multiplicity of small abrasive points at a regular selected interval during the use of the pad.



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